

## **Spectromicroscopy of low-dimensional systems**

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The present status of the spectromicroscopy project SPELEEM at the synchrotron radiation light source ELETTRA in Trieste, Italy, will be described. The SPELEEM (Spectroscopic Photo Emission and Low Energy Electron Microscope) of the Technical University of Clausthal, Germany, is connected to a branch of beamline 6.2 at the ELETTRA storage ring. It is a multimethod electron microscope which combines Low Energy Electron Microscopy (LEEM) with photoemission microscopy using synchrotron and UV light (PEEM). The microscope is equipped with an imaging electron energy analyser. The spatial resolution in photoemission mode is currently better than 25 nm, which is the highest so far reported for an instrument of this kind, while the energy resolution is better than 0.5 eV. The current photon energy range is 45 to 160 eV using light illuminating a 30 micron spot on the sample, which is incident at a grazing angle of 15 degrees. Recent applications of this method to current problems of semiconductor research like Schottky barrier homogeneity will illustrate its potential.